

HAT2024R

Silicon N Channel Power MOS FET
High Speed Power Switching

HITACHI

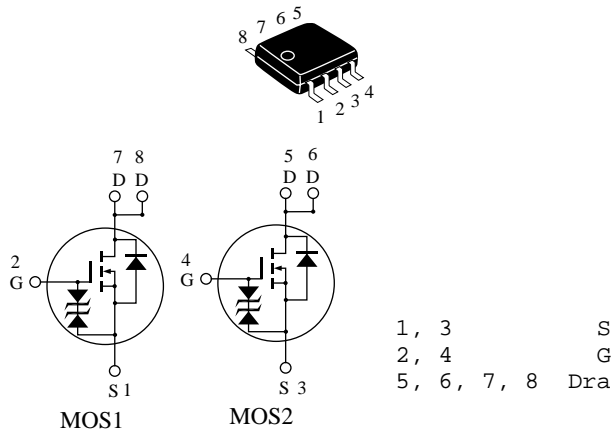
ADE-208-494 C (Z)
4th. Edition
July 1997

Features

- Low on-resistance
- Capable of 4 V gate drive
- Low drive current
- High density mounting

Outline

SOP-8



Absolute Maximum Ratings (Ta = 25°C)

| Item | Symbol | Ratings | Unit |
|---|---------------------|-------------|------|
| Drain to source voltage | V_{DSS} | 30 | V |
| Gate to source voltage | V_{GSS} | ±20 | V |
| Drain current | I_D | 5.5 | A |
| Drain peak current | $I_{D(pulse)}^{*1}$ | 44 | A |
| Body to drain diode reverse drain current | I_{DR} | 5.5 | A |
| Channel dissipation | Pch^{*2} | 2 | W |
| Channel dissipation | Pch^{*3} | 3 | W |
| Channel temperature | Tch | 150 | °C |
| Storage temperature | $Tstg$ | -55 to +150 | °C |

Notes: 1. $PW \leq 10\mu s$, duty cycle $\leq 1\%$

2. 1 Drive operation : When using the glass epoxy board (FR4 40 x 40 x 1.6 mm), $PW \leq 10s$

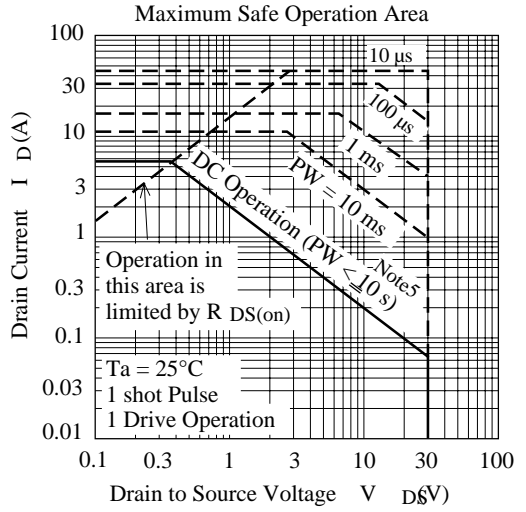
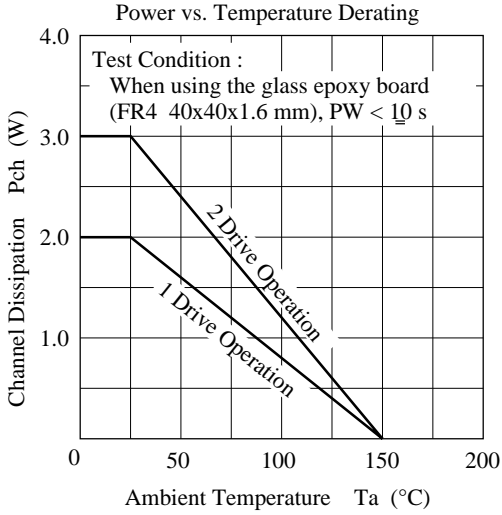
3. 2 Drive operation : When using the glass epoxy board (FR4 40 x 40 x 1.6 mm), $PW \leq 10s$

Electrical Characteristics (Ta = 25°C)

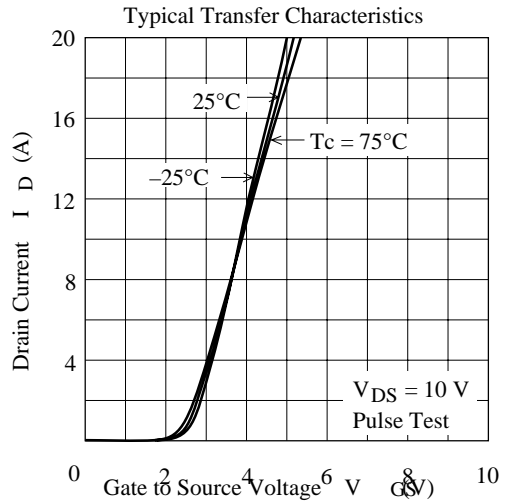
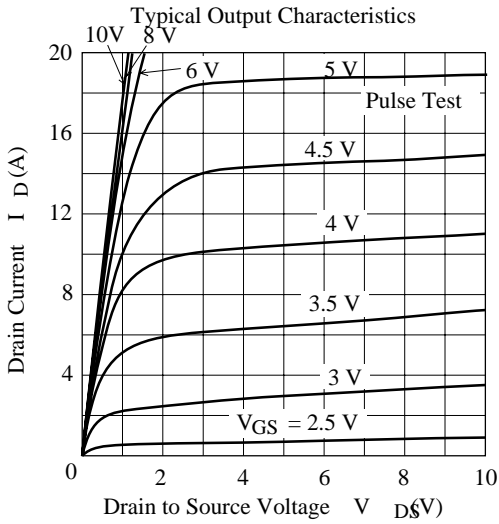
| Item | Symbol | Min | Typ | Max | Unit | Test Conditions |
|--|---------------|----------|-------|----------|---------------|--|
| Drain to source breakdown voltage | $V_{(BR)DSS}$ | 30 | — | — | V | $I_D = 10\text{mA}, V_{GS} = 0$ |
| Gate to source breakdown voltage | $V_{(BR)GSS}$ | ± 20 | — | — | V | $I_G = \pm 100\mu\text{A}, V_{DS} = 0$ |
| Gate to source leak current | I_{GSS} | — | — | ± 10 | μA | $V_{GS} = \pm 16\text{V}, V_{DS} = 0$ |
| Zero gate voltage drain current | I_{DSS} | — | — | 10 | μA | $V_{DS} = 30\text{V}, V_{GS} = 0$ |
| Gate to source cutoff voltage | $V_{GS(off)}$ | 1.0 | — | 2.0 | V | $V_{DS} = 10\text{V}, I_D = 1\text{mA}$ |
| Static drain to source on state resistance | $R_{DS(on)}$ | — | 0.05 | 0.065 | Ω | $I_D = 3\text{A}, V_{GS} = 10\text{V}^{*1}$ |
| | $R_{DS(on)}$ | — | 0.078 | 0.11 | Ω | $I_D = 3\text{A}, V_{GS} = 4\text{V}^{*1}$ |
| Forward transfer admittance | $ y_{fs} $ | 3.5 | 5.5 | — | S | $I_D = 3\text{A}, V_{DS} = 10\text{V}^{*1}$ |
| Input capacitance | C_{iss} | — | 310 | — | pF | $V_{DS} = 10\text{V}$ |
| Output capacitance | C_{oss} | — | 220 | — | pF | $V_{GS} = 0$ |
| Reverse transfer capacitance | C_{rss} | — | 100 | — | pF | $f = 1\text{MHz}$ |
| Turn-on delay time | $t_{d(on)}$ | — | 17 | — | ns | $V_{GS} = 4\text{V}, I_D = 3\text{A}$ |
| Rise time | t_r | — | 190 | — | ns | $V_{DD} \cong 10\text{V}$ |
| Turn-off delay time | $t_{d(off)}$ | — | 25 | — | ns | |
| Fall time | t_f | — | 60 | — | ns | |
| Body to drain diode forward voltage | V_{DF} | — | 0.9 | 1.4 | V | $I_F = 5.5\text{A}, V_{GS} = 0^{*1}$ |
| Body to drain diode reverse recovery time | t_{rr} | — | 50 | — | ns | $I_F = 5.5\text{A}, V_{GS} = 0$ $diF/dt = 20\text{A}/\mu\text{s}$ |

Note: 1. Pulse test

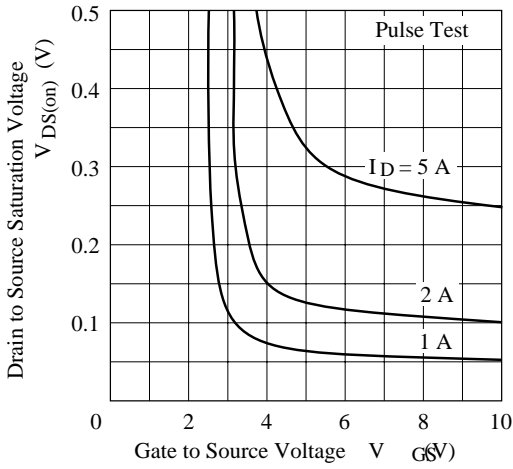
Main Characteristics



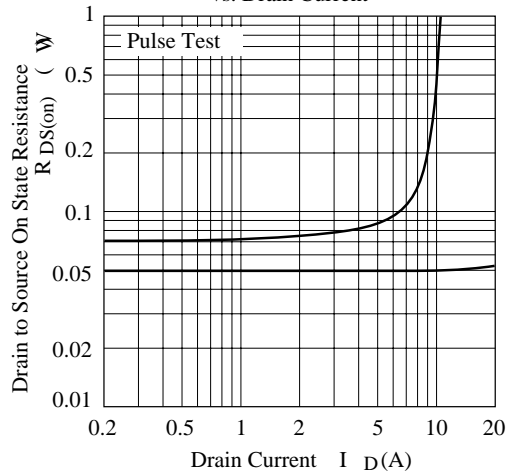
Note 5 :
When using the glass epoxy board
(FR4 40x40x1.6 mm)



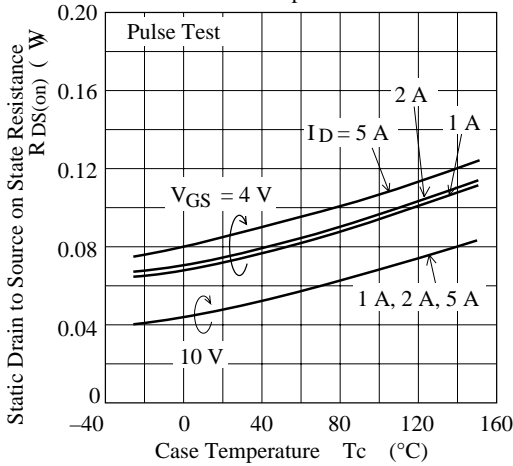
Drain to Source Saturation Voltage vs. Gate to Source Voltage



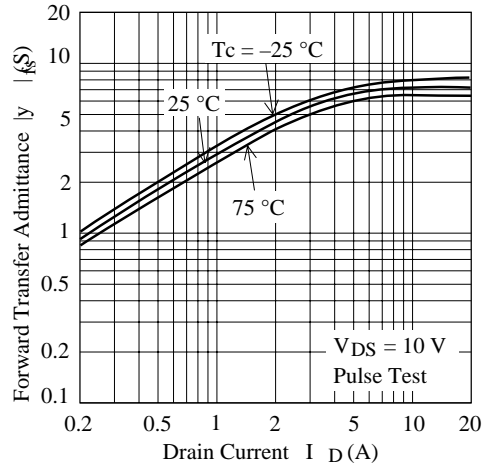
Static Drain to Source on State Resistance vs. Drain Current



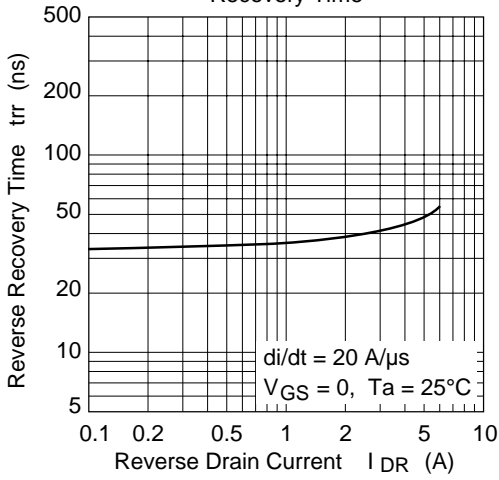
Static Drain to Source on State Resistance vs. Temperature



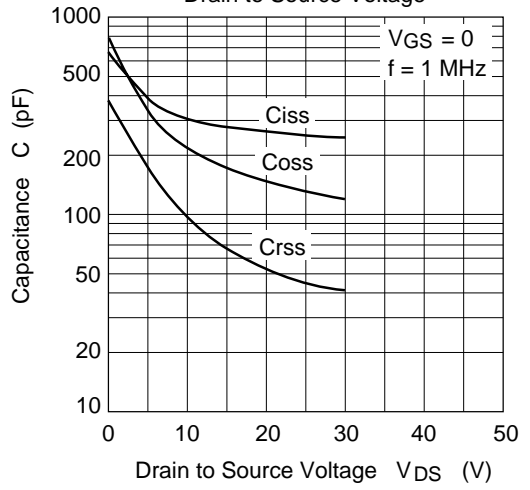
Forward Transfer Admittance vs. Drain Current



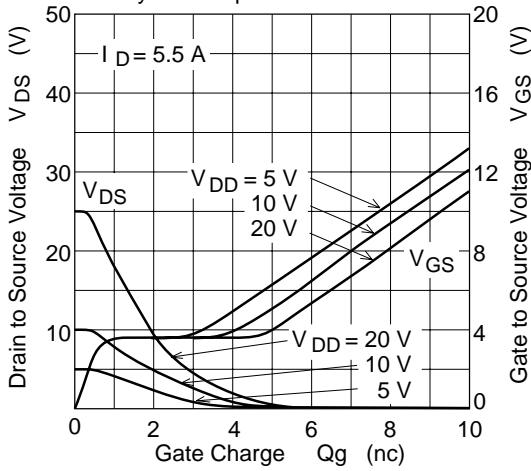
Body-Drain Diode Reverse Recovery Time



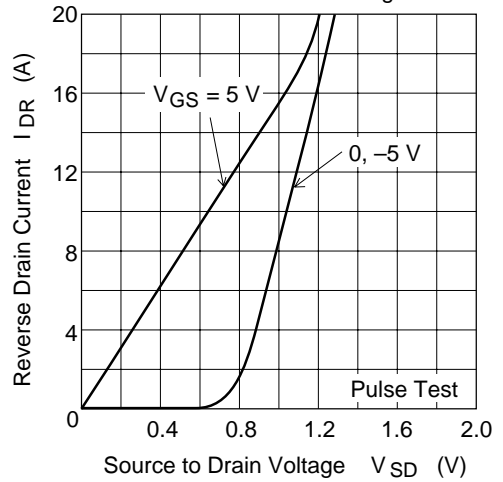
Typical Capacitance vs. Drain to Source Voltage

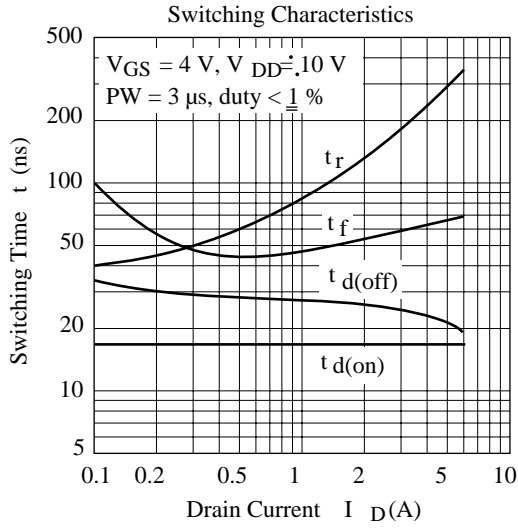


Dynamic Input Characteristics

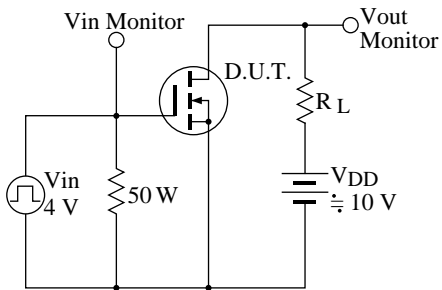


Reverse Drain Current vs. Source to Drain Voltage

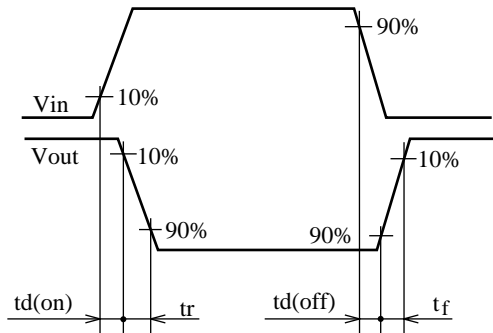


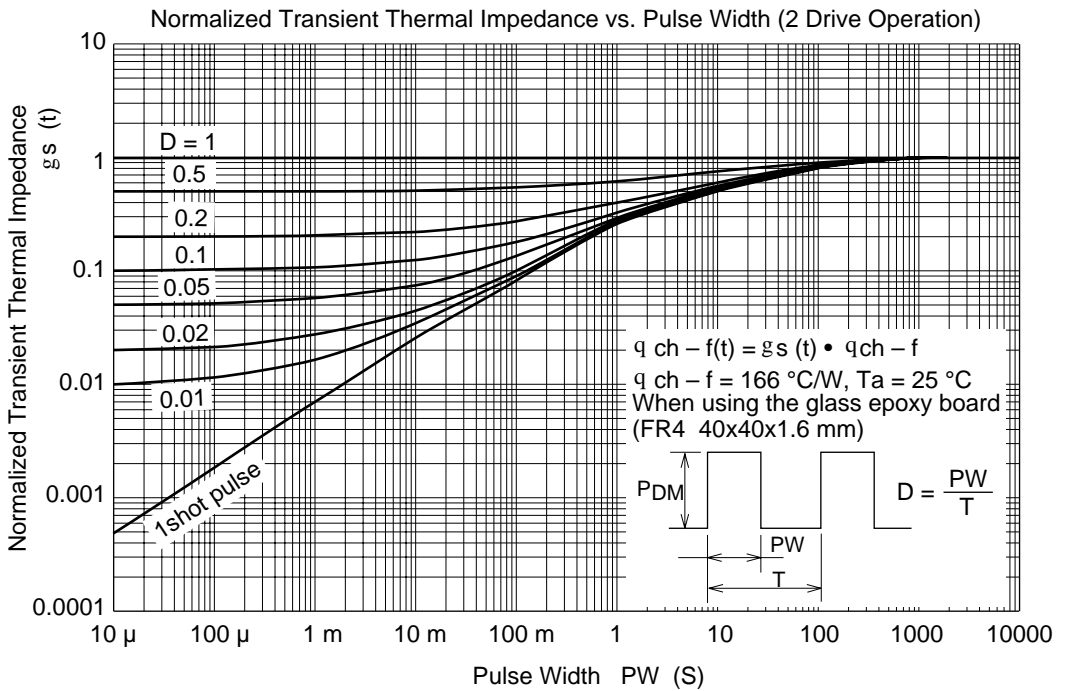
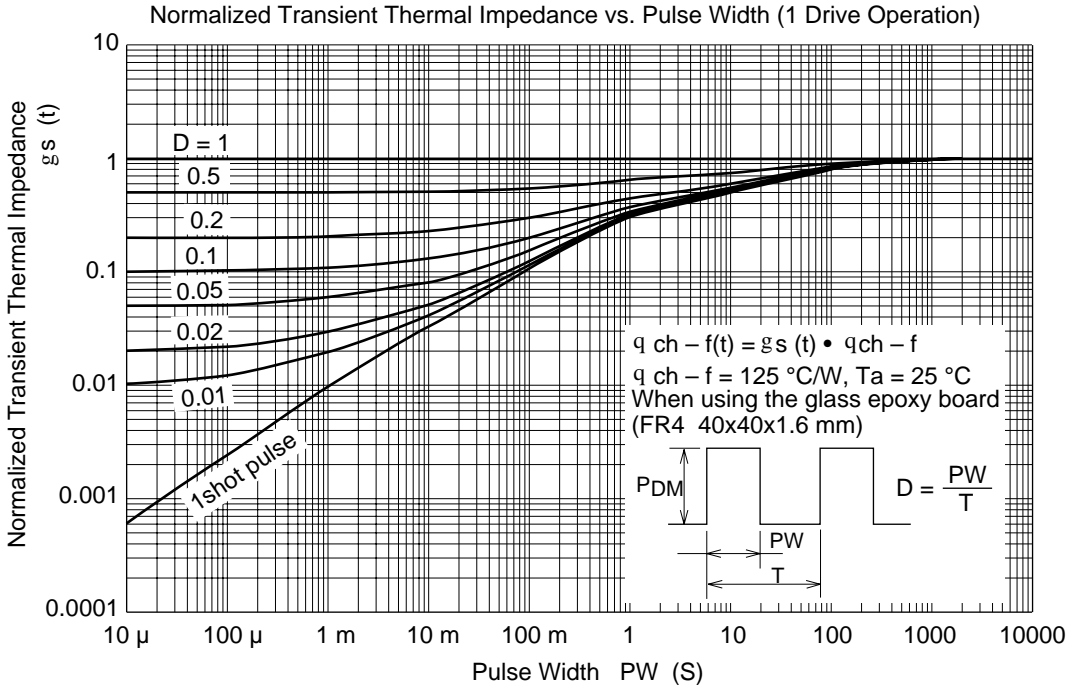


Switching Time Test Circuit



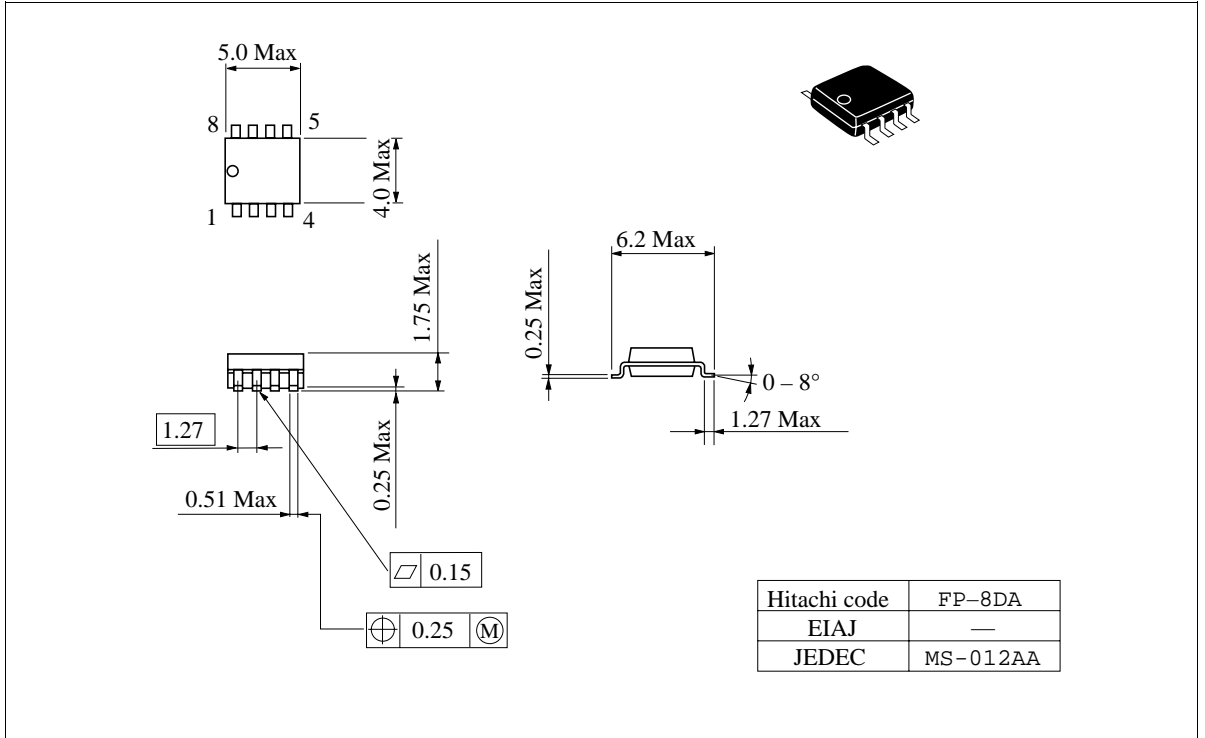
Switching Time Waveform





Package Dimensions

Unit: mm



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